



**INFORMATION CITED BY APPLICANT(S) THAT MAY BE MATERIAL TO THE PROSECUTION OF THE SUBJECT APPLICATION**

Applicants: Schwalbe et al. Attorney Docket No. CELL0017  
Serial No.: 09/617,068 Group Art Unit: 1764  
Filed: July 16, 2000 Examiner:  
Title: SEQUENTIAL REACTION SYSTEM

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OCT 25 2000  
GROUP 1

**U.S. PATENT DOCUMENTS**

*Examiner Initial	ID	Document No.	Date	Name	Class	Sub- Class
<u>M</u>	US1	* 4,748,002	5/31/1988	Neimark et al.	422	116
<u>M</u>	US2	* 5,122,345	6/16/1992	Tabor et al.	422	116
<u>M</u>	US3	* 5,288,468	2/22/1994	Church et al.	422	116
<u>M</u>	US4	* 5,324,483	6/28/1994	Cody et al.	422	131
<u>M</u>	US5	* 5,681,534	10/28/1997	Neves	422	131

**FOREIGN PATENT DOCUMENTS**

NONE CITED

**OTHER INFORMATION**

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RMA:mlb  
10/18/00



**SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT LISTING SHEET**

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TC 1700

Information Cited By Applicant(s) That May Be Material To  
The Prosecution Of The Subject Application

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**U.S. PATENT DOCUMENTS**

*Examiner Initial	ID	Document No.	Date	Name	Class	Sub- Class
	US1	5,273,715	12/28/1993	Bridgham et al.	422	63

**FOREIGN PATENT DOCUMENTS**

*Examiner Initial	ID	Document No.	Publication Date	Country	Class	Sub-Class	Translation?
<u>M</u>	F1	WO87/0139	09.04.1987	PCT	G01N35	00	No
<u>M</u>	F2	WO93/00625	07.01.1993	PCT	G05D7	00	No
<u>M</u>	F3	WO99/20395	29.04.1999	PCT	B01L3	02	No

**OTHER INFORMATION**

NONE CITED

  
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Date

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RMA:klp  
12/5/01



**SECOND SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT LISTING  
SHEET**

**Information Cited By Applicant(s) That May Be Material To  
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**U.S. PATENT DOCUMENTS**

*Examiner Initial	ID	Document No.	Date	Name	Class	Sub- Class
<u>KL</u>	US1	• 5,641,400	06/24/1997	Kaltenbach et al.	210	198
<u>IT</u>	US2	• 5,928,880	07/27/1999	Wilding et al.	435	7.21
<u>W</u>	US3	• 6,171,865	01/09/2001	Weigl et al	436	52
	US4	• 6,192,596	02/27/2001	Bennett et al.	34	76

**FOREIGN PATENT DOCUMENTS**

NONE CITED

**OTHER INFORMATION**

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RMA:MCK:ssa  
3/27/03

## U.S. PATENT DOCUMENTS

<u>*Examiner</u> <u>Initial</u>	<u>ID</u>	<u>Document No.</u>	<u>Date</u>	<u>Inventor Name(s)</u>	<u>Class</u>	<u>Sub-Class</u>
<i>ML</i>	US25	5,803,600	09/08/98	Schubert et al.	366	144
	US26	5,811,062	09/22/1998	Wegeng et al.	422	129
	US27	5,939,024	08/17/99	Robertson	422	101
	US28	5,961,932	10/05/1999	Ghosh et al.	422	193
	US29	5,976,472	11/02/1999	Chatterjee et al.	422	130
	US30	5,993,750	11/1999	Ghosh et al.	422	191
	US31	6,036,355	03/14/00	Yant et al.	366	171
	US32	6,036,927	03/2000	Chatterjee et al.	422	211
	US33	6,063,019	05/16/00	Wade	494	14
	US34	6,126,723	10/2000	Drost et al.	96	4
	US35	6,149,882	11/21/01	Guan et al	422	211
	US36	6,180,081	01/30/01	Poschmann et al.	423	648
	US37	6,190,034	02/20/01	Nielsen et al.	366	336
	US38	6,221,226	04/2001	Kopf-Sill	204	602
	US39	6,264,900	06/2001	Schubert et al.	422	224
	US40	6,494,614	12/17/02	Bennett et al.	336	36
	US41	6,537,506	03/2003	Schwable et al.	422	130
	US42	6,701,774	03/09/04	Srinivasan et al.	73	23.42
	US43	6,827,095	12/07/04	O'Connor et al	137	15.01
	US44	2002/0042140	04/11/02	Hagemeyer et al.	436	34
	US45	2002/0045265	04/18/02	Bergh et al.	436	37
	US46	2002/0080563	06/27/01	Pence et al.	361	677
<i>ML</i>	US47	2002/0151080	10/17/02	Dasgupta	422	055
	US48	2002/0170976	11/21/02	Bergh et al.	236	49.1

## FOREIGN PATENT DOCUMENTS

<u>*Examiner</u> <u>Initial</u>	<u>ID</u>	<u>Document No.</u>	<u>Publication</u> <u>Date</u>	<u>Country</u>	<u>Class</u>	<u>Sub-Class</u>	<u>Translation?</u>
<i>ML</i>	F1	DE 960 183	03/21/57	DE	B01J		No
	F2	EP0796654	03/21/97	EP	B01J	19/00	No
	F3	WO 98/38487	03/09/98	PCT	G01N	1/31	No
	F4	WO 98/55812	12/10/98	PCT	F28D	9/00	No
	F5	WO 99/04892	07/22/98	PCT	B01F	5/06	No
	F6	WO 00/34728	06/15/00	PCT	F28D	9	No
	F7	WO 00/51720	09/08/00	PCT	B01J/19	G01N	No
	F8	WO 00/62914	10/26/00	PCT	B01F	3/08	No
<i>ML</i>	F9	WO 00/62919	10/26/00	PCT	B01J	19/00	No

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<u>*Examiner Initial</u>	<u>ID</u>	<u>Document No.</u>	<u>Publication Date</u>	<u>Country</u>	<u>Class</u>	<u>Sub- Class</u>	<u>Translation?</u>
<u>ML</u>	F10	WO 01/41916	06/14/01	PCT	B01J	19/00	No
<u>I</u>	F11	WO 01/66245	09/13/01	PCT	B01J	19/00	No
<u>I</u>	F12	WO 01/68257	09/20/01	PCT	B01L	3/00	No
<u>NL</u>	F13	WO 01/93998	12/13/01	PCT	B01J		No

### OTHER INFORMATION

U O1 Van den Berg, A et al. 1996. "Modular Concept for Miniature Chemical Systems."  
*DECHEMA Monographs*: 132:109-23.

  
Examiner's Signature

06/22/06  
Date

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RMA:MCK:elm  
4/4/06